

Department of Electrical and Computer Engineering
UNIVERSITY OF BRITISH COLUMBIA
EECE 480 SEMICONDUCTOR DEVICES: PHYSICS, DESIGN and ANALYSIS
MID-TERM EXAM, October 20, 2009

Time: 1.25 hours

Notes, books and simple calculators are allowed.

Data-storage- or telecommunication-devices are not allowed.

This exam consists of **1** written page and **1** diagram.

1. [4 marks]

The E - k relationships for the conduction bands of two semiconductor materials, A and B , each with spherical constant-energy surfaces, can be expressed as

$$E_A - 0.7 = \alpha k^2 \quad \text{and} \quad E_B - 1.4 = 2\alpha(k - k')^2,$$

respectively, where α is a constant, $k' > 0$, and the energies are in units of eV.

Both materials have the same valence-band structure, with the top of the valence band at $E=0$ and $k=0$. Which material has the higher electron mobility?

2. [8 marks]

The partial energy band diagram shown on the back of this page is drawn to scale in the vertical dimension (1 mm \equiv 10 meV). Horizontally, the diagram is only approximately to scale.

From the diagram, determine the following:

- (a) whether the semiconductor is silicon or gallium arsenide;
- (b) the doping density of the n -region;
- (c) the doping density of the p -region;
- (d) the applied bias voltage (state whether it is forward or reverse).

3. [8 marks]

(a) Write down the master set of equations, as presented several times in class.

(b) Write down the equations from this set that you would use to solve for the steady-state electron current density in the p -type quasi-neutral region (p -QNR) of a diode.

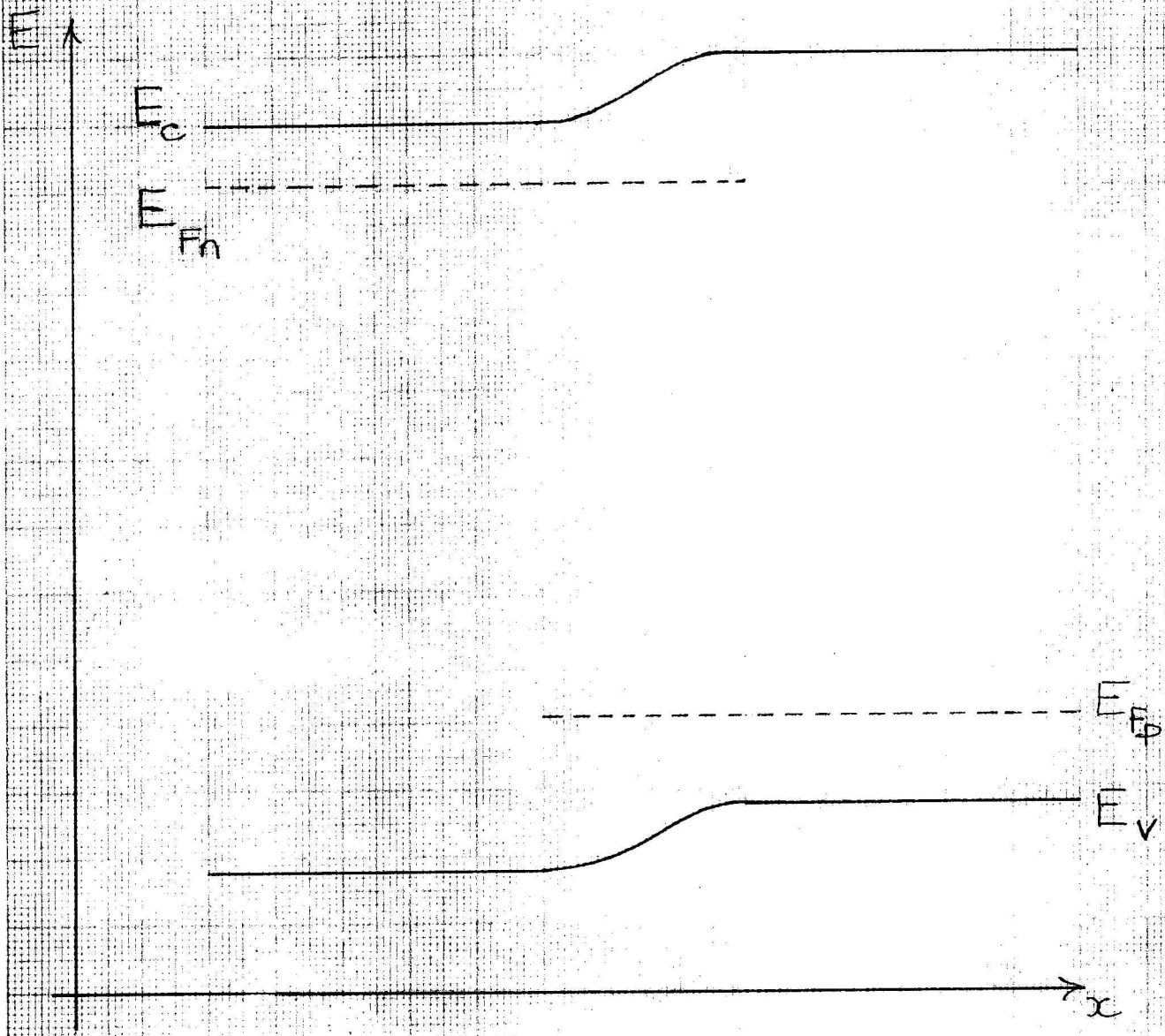
(c) Write down the boundary conditions for the electron concentration at either end of the p -QNR, given that the back contact is ohmic.

(d) Consider a short-base diode in which the width of the p -QNR is much, much, much less than the electron minority carrier diffusion length.

(i) Sketch the approximate profile of the excess minority carrier concentration ($n_p(x) - n_{0p}$) in the p -QNR.

(ii) Consider the diode to be made from silicon, and to have a p -type doping density of 10^{17} cm^{-3} , a p -QNR width of 100 nm, and to be subject to a forward bias of -0.8 V

Evaluate the electron current density in the p -type region.



Energy scale: $1\text{ mm} \equiv 10\text{ meV}$